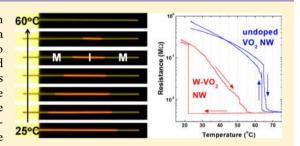


# Axially Engineered Metal—Insulator Phase Transition by Graded Doping VO<sub>2</sub> Nanowires

Sangwook Lee,  $^{\dagger}$  Chun Cheng,  $^{\dagger}$  Hua Guo,  $^{\S}$  Kedar Hippalgaonkar,  $^{\ddagger}$  Kevin Wang,  $^{\dagger}$  Joonki Suh,  $^{\dagger}$  Kai Liu,  $^{\dagger,\perp}$  and Junqiao Wu $^{*,\dagger,\perp}$ 

Supporting Information

ABSTRACT: The abrupt first-order metal—insulator phase transition in single-crystal vanadium dioxide nanowires (NWs) is engineered to be a gradual transition by axially grading the doping level of tungsten. We also demonstrate the potential of these NWs for thermal sensing and actuation applications. At room temperature, the graded-doped NWs show metal phase on the tips and insulator phase near the center of the NW, and the metal phase grows progressively toward the center when the temperature rises. As such, each individual NW acts as a microthermometer that can be simply read out with an optical microscope. The NW resistance decreases gradually with the temperature rise, eventually



reaching 2 orders of magnitude drop, in stark contrast to the abrupt resistance change in undoped VO<sub>2</sub> wires. This novel phase transition yields an extremely high temperature coefficient of resistivity  $\sim 10\%/K$ , simultaneously with a very low resistivity down to 0.001  $\Omega$ ·cm, making these NWs promising infrared sensing materials for uncooled microbolometers. Lastly, they form bimorph thermal actuators that bend with an unusually high curvature,  $\sim 900~\text{m}^{-1}\cdot\text{K}^{-1}$  over a wide temperature range (35–80 °C), significantly broadening the response temperature range of previous VO<sub>2</sub> bimorph actuators. Given that the phase transition responds to a diverse range of stimuli—heat, electric current, strain, focused light, and electric field—the graded-doped NWs may find wide applications in thermo-opto-electro-mechanical sensing and energy conversion.

# **■ INTRODUCTION**

Vanadium dioxide, a textbook example of strongly correlated electron material, is extremely interesting for exploration of condensed matter physics as well as various device applications. It undergoes a coupled structural—electronic phase transition from a monoclinic, insulating phase (I) at low temperatures to a rutile, metallic phase (M) at high temperatures. The metal—insulator transition (MIT) and structural transition occur concurrently at  $T_{\rm MIT}$  = 67 °C. Across the MIT, VO<sub>2</sub> exhibits a drastic change in optical transparency, several orders of magnitude drop in resistivity, and a specimen size change up to 1%. Exploiting these unique characteristics, a number of applications have been proposed or demonstrated, such as optical switch, smart window coating, Mott transistor, memristor, strain sensor, sensor, temperature sensor, and thermal actuator.

For all these applications, the functionality is within a very narrow temperature window around  $T_{\rm MIT}$ , because the phase transition is first-order and occurs abruptly only near  $T_{\rm MIT}$  = 67 °C. For many applications, it is necessary to tailor  $T_{\rm MIT}$  to meet different needs. Doping of transition metal into VO<sub>2</sub> is widely used to tune the  $T_{\rm MIT}$ .  $T_{\rm MIT}$  can be decreased or increased depending on the oxidation state of the dopant; substitution of V<sup>4+</sup> with W<sup>6+</sup>, Mo<sup>6+</sup>, and Nb<sup>5+</sup> lowers the  $T_{\rm MIT}$ , <sup>15–22</sup> whereas

Cr³+, Ga³+, and Al³+ raise it.²2²-2⁴ Among them, tungsten is known as the most effective dopant, enabling precise and widerange control of  $T_{\rm MIT}$ , reported with a nearly linear reduction rate of 18.4 °C/at.% for single-crystal VO₂ nanowires (NWs),¹⁵ 24 °C/at.% for polycrystal thin films,¹⁶ and 25–26 °C/at.% for powder and bulk single crystals.¹¹7,¹¹8 However, in all these cases, the W-doping of VO₂ is spatially homogeneous; therefore, it simply shifts  $T_{\rm MIT}$  to another value and does not modify the abrupt first-order nature of the MIT. The response temperature is still limited to a very narrow window around the new  $T_{\rm MIT}$ , and a wide temperature responsivity is lacking.

In this work, we lift this limit by engineering a spatially graded MIT along individual single-crystal VO<sub>2</sub> NWs. The VO<sub>2</sub> NWs are axially graded-doped with W, forming  $W_xV_{1-x}O_2$  NWs where x varies continuously along the NW axis, thus achieving a NW system that supports a MIT responding to a wide range of activation temperatures, practically analogous to a second-order phase transition. The M and I domains evolve gradually along the NW axis, leading to unique characteristics absent in undoped VO<sub>2</sub>: gradual but exceedingly large total changes in optical contrast, electrical resistivity, and NW length.

Received: January 24, 2013 Published: March 6, 2013

<sup>&</sup>lt;sup>†</sup>Department of Materials Science and Engineering and <sup>‡</sup>Department of Mechanical Engineering, University of California, Berkeley, California 94720, United States

<sup>&</sup>lt;sup>§</sup>National Center for Electron Microscopy and <sup>L</sup>Division of Materials Sciences, Lawrence Berkeley National Laboratory, Berkeley, California 94720, United States

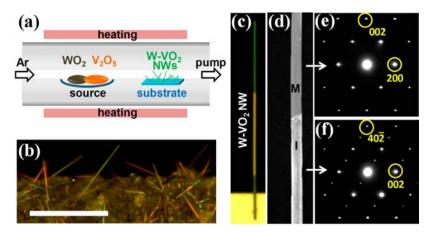


Figure 1. (a) Schematic of growing the graded-doped  $W_xV_{1-x}O_2$  NWs. (b) Optical image of an as-grown sample at room temperature (scale bar, 20  $\mu$ m). (c,d) Optical (c) and TEM (d) images of a typical graded-doped  $W_xV_{1-x}O_2$  NW (length ~32  $\mu$ m, width ~210 nm). The NW was transferred onto a Si substrate from the as-grown substrate. Optical images were taken using unpolarized white light. Visual color of the NW is a combined result of multiple factors including illumination light spectrum and resolution limit of the optics. (e,f) Electron diffraction pattern taken from the dark green region (e) and bright yellow region (f). The patterns are indexed to rutile (metallic phase, M) and monoclinic (insulating phase, I) structure of VO<sub>2</sub>, using rutile-[010] and monoclinic-[010] zone axes, respectively.

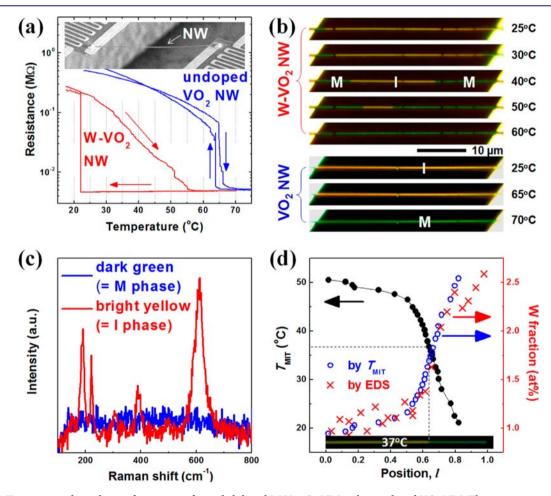


Figure 2. (a) Temperature dependence of resistance of a graded-doped  $W_xV_{1-x}O_2$  NW and an undoped  $VO_2$  NW. The resistance was measured on suspended pads (inset) to minimize strain. (b) Optical images of the graded-doped  $W_xV_{1-x}O_2$  NW device (upper panel) and the undoped  $VO_2$  NW device (lower panel) at various temperatures during heating. (c) Raman spectra taken from the dark part and the bright part of the graded-doped  $W_xV_{1-x}O_2$  NW. The peaks for the bright part are identified as I phase of  $VO_2$  (monoclinic). There are no peaks related to other stoichiometries of vanadium oxides. (d) Local MIT temperature (left axis) and W fraction (right axis). The latter was measured by EDS and calculated from the measured  $T_{\rm MIT}$ , respectively. The horizontal axis is positioned along the graded-doped NW from the center (l=0) to the tip (l=1). l=1 corresponds to 20  $\mu$ m. The inset shows an optical image of the analyzed NW at 37 °C as an example.

Enabled by these characteristics, we propose or demonstrate novel applications as an optically readable microthermometer, uncooled infrared bolometer, and bimorph thermal microactuator.

# ■ RESULTS AND DISCUSSION

The graded-doped  $W_xV_{1-x}O_2$  NWs were grown by the vapor transport method as schematically shown in Figure 1a, similar to a previous growth method for high-density undoped VO2 wires, 25 except that WO<sub>2</sub> powder was added as W-doping source. Downstream, NWs were produced on an unpolished quartz substrate, as shown in Figure 1b. The as-synthesized NWs free stand randomly on the substrate, and the lengths are in the range of 5-50  $\mu$ m. Figure 1c shows optical image of a typical NW (length ~32 μm, width ~210 nm) cantilevered from the edge of a substrate. Most notably, at room temperature, the M and I phases coexist axially within the single NW. It is well known that these two phases are clearly distinguishable by their optical reflection under white light illumination: the dark domain (dark green in this work) is the M phase, and the bright domain (bright yellow in this work) is the I phase. Almost all NWs have three distinctive domains: M phase at both tips and I phase in the middle part. These phases were cross-checked by transmission electron microscopy (TEM). The selected area electron diffraction (SAED) pattern of the NW (Figure 1e,f) shows that the dark green part is indeed M phase (rutile, P42/mnm), while the bright yellow part is I phase (monoclinic,  $P2_1/c$ ). The single-crystallinity of the NW is confirmed by the fact that the SAED pattern does not vary when taken at different spots along the NW axis. Therefore, it is clear that the tips of the NWs are W-doped more heavily than the middle part, such that the  $T_{\rm MIT}$  at the tips is below room temperature, while at the middle part it is above room temperature.

In the optical and TEM imaging above, the NW is freestanding. This is important in order to probe the intrinsic phase transition and domain structure. It has been shown that, under strain, the MIT temperature and the M-I domain structure of VO<sub>2</sub> appear different from those of free-standing VO<sub>2</sub>.<sup>3,4</sup> A freestanding VO2 NW or a free-standing uniformly W-doped VO2 NW undergoes the MIT abruptly when temperature is raised across its  $T_{\text{MIT}}$ . However, when the same NW is assembled into a two-probe device where the two ends (and only the two ends) are firmly clamped on a rigid substrate by electrodes, the M phase grows gradually along the NW as a function of temperature.<sup>26</sup> This is because this is the minimum-energy M-I domain structure of the NW when an additional elastic energy term is introduced by strain accumulated in such an end-end clamped configuration. <sup>26,27</sup> Therefore, externally imposed strain should be avoided when the intrinsic MIT behavior is to be characterized.

To eliminate strain accumulation in measuring the electrical resistance of these NWs, we use the suspended microdevice pads typically used for isolated thermal transport measurements; here the pads are conductive and suspended by long flexural arms, serving as two electrical contacts to the NW. Unlike ordinary NW devices firmly clamped on solid substrates, however, in our case the suspended pads are free to move, and thus the NW is free to shrink or elongate to avoid axial strain accumulation. A single NW was transferred to bridge the two pads (Figure 2a, inset), and Pt was deposited to bond the NW onto the pads using a focused ion beam (see Figure S1, Supporting Information). A number of  $W_xV_{1-x}O_2$  and undoped

VO<sub>2</sub> devices (number >5) were fabricated in this way. The typical length and width of NWs are  $\sim$ 40  $\mu$ m and  $\sim$ 300 nm, respectively. All devices showed linear I-V curves, indicating ohmic contacts. Figure 2a plots a typical resistance-temperature curve of a graded-doped W<sub>x</sub>V<sub>1-x</sub>O<sub>2</sub> NW and an undoped VO2 NW. Here the temperature ramping rate is controlled to be very slow (<2.5 °C/min), to eliminate kinetic effects. The undoped VO<sub>2</sub> NW shows an expected<sup>3</sup> sharp resistance switching around 67 °C with a ~2 °C hysteresis. We note that the  $T_{\rm MIT}$  may be also affected by chemical nonstoichiometry of the NW.<sup>29</sup> In stark contrast, resistance of the graded-doped W<sub>x</sub>V<sub>1-x</sub>O<sub>2</sub> NW decreases gradually from room temperature to 60 °C without the abrupt resistance switching. This resistance behavior results in an exceedingly large temperature coefficient of resistivity (TCR) of  $-(12 \pm 2)\%$ /K. The TCR is defined as  $(1/\rho)(d\rho/dT) =$  $d(\ln \rho)/dT$ ), where  $\rho$  is resistivity. The TCR is a key parameter for many thermal sensing applications, such as electrical thermometers and infrared bolometers (see below).

The origin of this gradual MIT that lasts over a  $\Delta T = 30$  °C can be understood from the concurrently taken optical images of the graded-doped NW. As shown in Figure 2b, with the increase in temperature, the M phase grows out of the two ends of the NW, followed by a progressive invasion into the I phase toward the middle of the NW, and the entire NW turns into a single M phase at 55-60 °C. Such a domain behavior was observed from all graded W-doped VO<sub>2</sub> NWs, but not from the undoped VO2 NWs. Moreover, even when the NW was cantilevered at one end from the edge of a heated substrate, the M phase grew from both the root and the tip of the NW (Figure S2, Supporting Information). Therefore, we rule out the possibility that temperature gradient along the NW axis might cause this domain behavior. The axially progressed M-I domain wall means that the local  $T_{\rm MIT}$  itself is encoded by the growth, and varies gradually along the axis, from heavily Wdoped tips to a lightly W-doped center. The coexisting M and I phases along a single NW is further confirmed by their micro-Raman spectra in Figure 2c. Figure 2d shows axially varying  $T_{\rm MIT}$  from the center (position l=0) to one of the tips (l=1)of a graded-doped  $W_xV_{1-x}O_2$  NW, and the W-doping fraction measured along the NW axis by energy dispersive X-ray spectroscopy (EDS). The EDS results verify that the NW is graded W-doped and the doping level increases from 1.0 at.% at l = 0 to 2.6 at.% at l = 1. The measured W-doping level agrees well with the predicted W fraction (also plotted in Figure 2d), converted from the measured  $T_{\rm MIT}$  using the  $T_{\rm MIT}$  reduction rate, -18.4 °C/at.% of W, reported from homogeneously W-doped VO<sub>2</sub> NWs. <sup>15</sup> We note that when the graded-doped  $W_rV_{1-r}O_2$  NWs are cooled from high temperatures where the NW is in full M state, they always show a large hysteresis as in Figure 2a. On the other hand, when they are cooled from an M-I-M domain configuration at intermediate temperatures, they show only a small (<5 °C) hysteresis followed by a gradual transition back to the full I state. This is an effect of large supercooling because of the lack of nucleation site for the transition starting from the full M state. As shown in our previous work,<sup>30</sup> the M-I domain wall or twin walls in VO<sub>2</sub> can serve as sites to seed the growth of new phase, thus eliminate superheating or supercooling during the MIT. However, when the NW is fully in the M state, an M-I wall is absent, and the tetragonal crystal structure of the M-phase also precludes the possibility of structural twining. Therefore the system has to undergo a large supercooling before the first I domain appears.

This is not the case for the transition starting from an M-I-M state where the M-I domain wall acts as the seed for growth of new phase. Therefore, a large kinetic asymmetry with a strong supercooling is seen in the MIT of these NWs.

Due to the stark color contrast between the M and I domains, the M-I domain wall can be easily resolved with an optical microscope. Its axial progress with temperature rise naturally offers a single-NW microthermometer that can be optically read out. Optically readable microthermometers have been demonstrated utilizing temperature-sensitive light emission of quantum dots<sup>31</sup> or molecules.<sup>32</sup> However, in those cases an excitation light source and a spectrometer are needed to record and spectrally resolve the emitted light. In our case by a rapid, simple optical imaging of the M-I domain wall position along the NW, local temperature can be determined after proper calibration. Moreover, the temperature range over which the NW thermometer works is between room temperature and ~60 °C, a temperature range of special importance in biology and microfluidics. We note that an undoped VO<sub>2</sub> NW can also support an axially gradual MIT when it is firmly clamped at its two ends on a rigid substrate.<sup>26</sup> However, the requirement of end clamping is undesired for application, while in our case this is achieved with W-doping.

Now we turn to another potential application, infrared detection. For electromagnetic radiation in the far-infrared spectral range, conventional p-n junction based photodetectors do not work because the infrared light energy is below their bandgap. In this case bolometers are typically used, which measure the incident infrared light intensity by monitoring the resistance (R) change of an infrared-sensing material. The material absorbs the infrared light and heats up, thus lowering its R. Typical bolometers are cooled by liquid helium to reduce optical and electrical noises, which add undesired cost, volume and weight. For uncooled bolometers, high performance requires the following properties from the sensing material: (1) strong infrared absorption to maximize efficiency, (2) a high TCR for maximum sensitivity, and (3) a low resistivity ( $\rho$ ) to minimize thermal noise and Joule heating. Achieving a high TCR and simultaneously low  $\rho$  is a challenge for semiconductors because they are mutually exclusive:  $\rho = \rho_0 \exp(E_a/E_a)$  $k_BT$ ), and TCR =  $(1/\rho)(d\rho/dT) = -E_a/k_BT^2$ , where  $E_a$  is the thermal activation energy of  $\rho$ . Therefore, a high TCR typically correlates with a high  $\rho$ .

VO<sub>2</sub> thin films have a relatively high TCR of 2-5%/K in the I phase, but their high  $\rho$  of 0.1–1  $\Omega$ ·cm makes them unsuitable for uncooled bolometer application. 33,34 Moreover, their abrupt, first-order MIT is considered as a nuisance that needs to be avoided, because it introduces high nonlinearity in the sensing response. Other vanadium oxide (VO<sub>x</sub>) thin films with various stoichiometries free of MIT have been used as commercial bolometer sensing material, taking advantage of their strong infrared absorption, relatively high TCR (2-3%/ K) and low  $\rho$  (0.05–0.1  $\Omega$ ·cm). 33,34 Our graded W-doped VO<sub>2</sub> offers a new, superior bolometer material by exploiting the MIT, as opposed to avoiding it. First of all, VO2 and W-doped  ${
m VO_2}$  are intrinsically strongly absorptive in the far-infrared region, especially in the M phase. Figure 3 plot the TCR and  $\rho$  of the graded-doped  $W_xV_{1-x}O_2$  NWs compared to  $VO_x$ thin films that are currently used as the working material for uncooled bolometers. The graded-doped W<sub>x</sub>V<sub>1-x</sub>O<sub>2</sub> NWs exhibit an exceptionally high TCR on the order of 10%/K, together with a low  $\rho$  between 0.001 and 0.1  $\Omega$ ·cm. These two parameters are superior to VO<sub>2</sub> thin films, <sup>33,34,37,38</sup> VO<sub>x</sub> thin

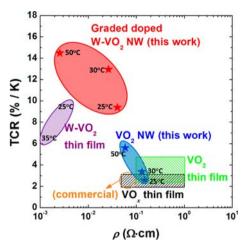
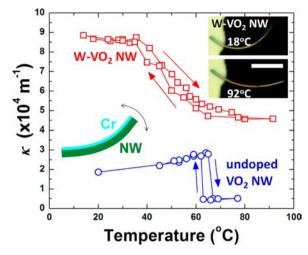


Figure 3. Temperature coefficient of resistivity versus resistivity of various sensing materials for uncooled infrared bolometer. The graded-doped  $W_xV_{1-x}O_2$  NW is compared with  $VO_x$  thin films (refs 33, 34, 39–41),  $VO_2$  thin films (refs 33, 34, 37, 38), W-doped  $VO_2$  (1.5 at.%) thin film (ref 20), and  $VO_2$  NW (this work). The stars are the data points measured in this work. An ideal bolometer material prefers high TCR and low  $\rho$ .

films,  $^{33,34,39-41}$   $W_xV_{1-x}O_2$  (x=0.015) thin films,  $^{20}$  and undoped VO2 NW. Therefore, the spatial progressing MIT of graded W-doped VO2 presents a new candidate for prospective bolometer material by offering  $\sim 5$  times higher TCR simultaneously with a lower  $\rho$  than commercially used bolometer materials. Compared to polycrystal VO $_x$  thin films, the graded-doped single-crystal  $W_xV_{1-x}O_2$  may have other advantages: (1) possibly low 1/f noise (another main factor affecting device sensitivity) because of its single-crystallinity and thus much fewer domain/grain boundaries;  $^{42}$  and (ii) high effective infrared absorption due to the existence of the M phase with an absorption coefficient 5–100 times higher than that of the I phase in the infrared range of wavelength  $> \sim 8$   $\mu \rm m.^{43,44}$ 

The axially engineered MIT in the graded-doped  $W_xV_{1-x}O_2$ NWs also provides a means for constructing broad-range thermal microactuators. It is known that accompanying the MIT in VO<sub>2</sub>, the structural phase transition introduces a spontaneous strain,  $\varepsilon \approx 1\%$ , along the rutile c-axis  $(c_R)^2$ . In NWs where the wire axis is always along  $c_R$ , the strain causes an abrupt shrinkage of the NW length by 1%. This effect has recently been used for thermal microactuators, in which a VO<sub>2</sub> NW is mechanically coupled with an inactive layer forming a bimorph. Crossing the MIT, the bimorph bends to high curvatures  $(\kappa)$ , and outputs actuation at high force, high amplitude, and high speed compared to conventional actuators. 14,45-47 This phase transition-based actuation, however, is triggered abruptly near the VO<sub>2</sub> MIT temperature, ~67 °C, and does not respond to lower driving temperatures, which limits the operation responsivity, as shown in Figure 4. We found that W-doping retains the 1% spontaneous strain in VO<sub>2</sub> (Figure S3, Supporting Information), yet the NW length shrinkage occurs gradually instead of abruptly. This property offers a way to lower the temperature threshold and broaden the response range of undoped VO<sub>2</sub> actuators. Figure 4 shows the temperature-dependent  $\kappa$  change of a bimorph actuator comprised of a graded-doped W<sub>x</sub>V<sub>1-x</sub>O<sub>2</sub> NW coupled to a Cr overlayer as shown in the inset. The length and thickness of the NW are  $\sim$ 24  $\mu$ m and  $\sim$ 250 nm, respectively. We coated  $\sim$ 90



**Figure 4.** Temperature dependence of bending curvature of two bimorph thermal actuators, Cr on a graded-doped  $W_xV_{1-x}O_2$  NW, and Cr on an undoped VO<sub>2</sub> NW. Upper inset shows optical images of the  $W_xV_{1-x}O_2$ -based actuator (scale bar, 10  $\mu$ m) at 18 and 92 °C, and lower inset shows a scheme of the bimorph structure.

nm of Cr onto one side of the NW, because the maximum curvature change  $(\Delta \kappa)$  of a Cr/VO<sub>2</sub> bimorph is expected at a thickness ratio of  $\sim 0.37$ . In contrast to the Cr/VO<sub>2</sub> bimorph, the  $\kappa$  of the  $Cr/W_xV_{1-x}O_2$  changes gradually over a temperature range of 35-80 °C, with a rate  $\Delta \kappa / \Delta T \approx 900$ m<sup>-1</sup>·K<sup>-1</sup>, leading to an overall  $\Delta \kappa \approx 4 \times 10^4$  m<sup>-1</sup>. This wider range of working temperature, gradual  $\kappa$  change, and smaller  $\Delta \kappa / dT$  (compared to Cr/VO<sub>2</sub> bimorph) allow precise control of the actuation displacement, while outputting large amplitude of the displacement. Moreover, it has been shown that VO<sub>2</sub> provides a high volumetric work density  $(Y\varepsilon^2/2$ , where Y = 140GPa is the Young's modulus) up to 7 J/cm<sup>3</sup>. This allows the Cr/VO<sub>2</sub> bimorph actuator to deliver simultaneously high force and large amplitude in actuation. This work density is comparable to shape memory alloys, more than 10 times higher than that of most organic materials and electrostrictive polymers, hundreds of times higher than that of piezoelectric materials, and 3 orders of magnitude higher than that of human muscles.4

#### CONCLUSION

In summary, we synthesized W-doped VO<sub>2</sub> NWs where the doping level is axially graded from the two tips toward the center of the NW. These W<sub>x</sub>V<sub>1-x</sub>O<sub>2</sub> NWs exhibit axially graded metal-insulator phase transition and structural transition. Their extremely high temperature coefficient of resistivity, combined with the low resistivity, make them good candidates for farinfrared sensing material in uncooled bolometers; the high optical contrast between the two phases renders each individual NW an optically readable microthermometer; the gradual structural transition allows to form bimorph microactuators with high amplitude and wide temperature responsivity. We note that the coupled structural-electronic phase transition of  $VO_2$  and  $W_xV_{1-x}O_2$  can be activated by a diverse range of external stimuli: heat, electric current, 15 strain, 3 focused light, 14 and electrical field. 49,50 Consequently, the graded-doped  $W_xV_{1-x}O_2$  NWs may find extensive applications in microscale thermo-opto-electro-mechanical signal transduction and energy conversion.

## **■ EXPERIMENTAL SECTION**

Growth and Characterization of Graded-Doped  $W_xV_{1-x}O_2$  NWs. The graded-doped  $W_xV_{1-x}O_2$  NWs were synthesized using a vapor transport scheme modified from a previously reported method.  $^{25}$   $V_2O_5$  and 20 wt% of  $WO_2$  powder were placed in a quartz boat in the center of a horizontal tube furnace, and evaporated at 880 °C for 10 min, with Ar as the carrier gas (6.8 sccm) at 4 Torr of pressure. The reaction product was collected at 850 °C on an unpolished quartz substrate from downstream of the evaporated sources. The mechanism of axially graded doping of W in the  $VO_2$  NWs is not yet fully understood, but a tentative explanation is given in the Supporting Information. The morphology, crystal structure, crystal orientation, and doping level of these NWs were characterized by optical microscopy, SEM, TEM, Raman spectroscopy, and EDS in TEM.

Fabrication and Characterization of NW-Based Devices. In order to measure the electrical property free of strain accumulation, we used suspended, flexural micropads to make electrical devices. Electrically conductive Pt lines were coated on the suspended pads and arms. An individual as-grown NW was transferred between two suspended, parallel pads, and Pt was deposited onto both ends of the NW using focused ion beam for good electrical contact with the pads. To make Cr/NW bimorph microactuators, Cr layers were deposited onto one side of graded-doped  $W_x V_{1-x} O_2$  NWs by electron-beam evaporation with a deposition rate of 0.2 nm/s. The microactuators always bend toward Cr layer due to built-in stress between the Cr and the NW during the Cr evaporation. The sample temperature was controlled by global heating/cooling of the entire device with a ramping rate of 2.5 °C/min, using an electrical microheater combined with a resistive temperature sensor.

# ASSOCIATED CONTENT

# Supporting Information

Suspended pad device for electrical measurements, NW domain configuration at increasing temperatures, NW length change over the phase transition, and proposed growth mechanism. This material is available free of charge via the Internet at http://pubs.acs.org.

## AUTHOR INFORMATION

## **Corresponding Author**

wuj@berkeley.edu

## Notes

The authors declare no competing financial interest.

## ACKNOWLEDGMENTS

This work was supported by the National Science Foundation under Grant No. ECCS-1101779.

# REFERENCES

- (1) Eyert, V. Ann. Phys. 2002, 11, 650.
- (2) Marezio, M.; McWhan, B.; Dernier, P. D.; Remeika, J. P. *Phys. Rev. B* **1972**, *5*, 2541.
- (3) Cao, J.; Ertekin, E.; Srinivasan, V.; Fan, W.; Huang, S.; Zheng, H.; Yim, J. W. L.; Khanal, D. R.; Ogletree, D. F.; Grossman, J. C.; Wu, J. Nat. Nanotechnol. 2009, 4, 732.
- (4) Wu, J.; Gu, Q.; Guiton, B. S.; de Leon, N. P.; Ouyang, L.; Park, H. Nano Lett. 2006, 6, 2313.
- (5) Berglund, C. N.; Guggenheim, H. J. Phys. Rev. 1969, 185, 1022.
- (6) Goodenough, J. B. J. Solid State Chem. 1971, 3, 490.
- (7) Chain, E. E. Appl. Opt. 1991, 30, 2782.
- (8) Gao, Y. F.; Wang, S. B.; Kang, L. T.; Chen, Z.; Du, J.; Liu, X. L.; Luo, H. J.; Kanehira, M. Energy Environ. Sci. 2012, 5, 8234.
- (9) Hormoz, S.; Ramanathan, S. Solid-State Electron. 2010, 54, 654.
- (10) Coy, H.; Cabrera, R.; Sepúlveda, N.; Fernández, F. E. J. Appl. Phys. 2010, 108, 113115.

- (11) Hu, B.; Zhang, Y.; Chen, W.; Xu, C.; Wang, Z. L. Adv. Mater. 2011, 23, 3536.
- (12) Strelcov, E.; Lilach, Y.; Kolmakov, A. Nano Lett. 2009, 9, 2322.
- (13) Kim, B.-J.; Lee, Y. W.; Chae, B.-G.; Yun, S. J.; Oh, S.-Y.; Kim, H.-T.; Lim, Y.-S. Appl. Phys. Lett. **2007**, 90, 023515.
- (14) Liu, K.; Cheng, C.; Cheng, Z. T.; Wang, K.; Ramesh, R.; Wu, J. Nano Lett. **2012**, 12, 6302.
- (15) Gu, Q.; Falk, A.; Wu, J.; Ouyang, L.; Park, H. Nano Lett. 2007, 7, 363.
- (16) Jin, P.; Nakao, S.; Tanemura, S. Thin Solid Films 1998, 324, 151.
- (17) Rakotoniaina, J. C.; Mokrani-Tamellin, R.; Gavarri, J. R.; Vacquier, G.; Casalot, A.; Calvarin, G. J. Solid State Chem. 1993, 103, 81
- (18) Hörlin, T.; Niklewski, T.; Nygren, M. Mater. Res. Bull. 1972, 7, 1515.
- (19) Whittaker, L.; Wu, T.-L.; Stabile, A.; Sambandamurthy, G.; Banerjeej, S. ACS Nano 2011, 5, 8861.
- (20) Takami, H.; Kawatani, K.; Kanki, T.; Tanaka, H. Jpn. J. Appl. Phys. 2011, 50, 055804.
- (21) Wu, Z. P.; Miyashita, A.; Yamamoto, S.; Abe, H.; Nashiyama, I.; Narumi, K.; Naramoto, H. *J. Appl. Phys.* **1999**, *86*, 5311.
- (22) Fisher, B. Phys. Chem. Solids 1982, 43, 205.
- (23) Brückner, W.; Gerlach, U.; Moldenhauer, W.; Brückner, H. P.; Mattern, N.; Oppermann, H.; Wolf, E. *Phys. Status Solidi A* **1976**, 38, 93
- (24) Strelcov, E.; Tselev, A.; Ivanov, I.; Budai, J. D.; Zhang, J.; Tischler, J. Z.; Kravchenko, I.; Kalinin, S. V.; Kolmakov, A. *Nano Lett.* **2012**, *12*, 6198.
- (25) Cheng, C.; Liu, K.; Xiang, B.; Suh, J.; Wu, J. Appl. Phys. Lett. **2012**, 100, 103111.
- (26) Wei, J.; Wang, Z. H.; Chen, W.; Cobden, D. H. Nat. Nanotechnol. 2009, 4, 420.
- (27) Tselev, A.; Meunier, V.; Strelcov, E.; Shelton, W. A.; Luk'yanchuk, I. A.; Jones, K.; Proksch, R.; Kolmakov, A.; Kalinin, S. V. ACS Nano 2010, 4, 4412.
- (28) Kim, P.; Shi, L.; Majumdar, A.; McEuen, P. L. Phys. Rev. Lett. 2001, 87, 215502.
- (29) Zhang, S.; Kim, I. S.; Lauhon, L. J. Nano Lett. 2011, 11, 1443.
- (30) Fan, W.; Cao, J.; Seidel, J.; Gu, Y.; Yim, J. W.; Barrett, C.; Yu, K. M.; Ji, J.; Ramesh, R.; Chen, L. Q.; Wu, J. *Phys. Rev. B* **2011**, 83, 235102.
- (31) Li, S.; Zhang, K.; Yang, J.-M.; Lin, L. W.; Yang, H. Nano Lett. 2007, 7, 3102.
- (32) Wienken, C. J.; Baaske, P.; Rothbauer, U.; Braun, D.; Duhr, S. *Nat. Commun.* **2010**, *1*, 100.
- (33) Gurvitch, M.; Luryi, S.; Polyakov, A.; Shabalov, A. *J. Appl. Phys.* **2009**, *106*, 104504.
- (34) Niklaus, F.; Vieider, C.; Jakobsen, H. Proc. SPIE **200**7, 6836, 68360D-1.
- (35) Fu, D.; Liu, K.; Tao, T.; Lo, K.; Cheng, C.; Liu, B.; Zhang, R.; Bechtel, H. A.; Wu, J. J. Appl. Phys. **2013**, 113, 043707.
- (36) Soltani, M.; Chaker, M.; Haddad, E.; Kruzelecky, R.; Margot, J. J. Vac. Sci. Technol. A 2007, 25, 971.
- (37) Cheng, Q.; Paradis, S.; Bui, T.; Almasri, M. IEEE Sens. J. 2011, 11, 167.
- (38) Gurvitch, M.; Luryi, S.; Polyakov, A.; Shabalov, A.; Dudley, M.; Wang, G.; Ge, S.; Yakovlev, V. J. Appl. Phys. **2007**, 102, 033504.
- (39) Kang, H. K.; Han, Y. H.; Shin, H. J.; Moon, S.; Kim, T. H. J. Vac. Sci. Technol. B 2003, 21, 1027.
- (40) Wang, B.; Lai, J. J.; Zhao, E. J.; Hu, H. M.; Liu, Q.; Chen, S. H. Opt. Eng. 2012, 51, 074003.
- (41) Radford, W.; Murphy, D.; Ray, M.; Propst, S.; Kennedy, A.; Kojiro, J.; Woolaway, J.; Soch, K. *Proc. SPIE* **1996**, *2746*, 88.
- (42) Kruse, P. W. Proc. SPIE 2004, 5406, 437.
- (43) Coath, J. A.; Richardson, M. A. Proc. SPIE 1999, 3738, 555.
- (44) Kats, M. A.; Sharma, D.; Lin, J.; Genevet, P.; Blanchard, R.; Yang, Z.; Qazilbash, M. M.; Basov, D. N.; Ramanathan, S.; Capasso, F. Appl. Phys. Lett. **2012**, 101, 221101.

- (45) Cao, J.; Fan, W.; Zhou, Q.; Sheu, E.; Liu, A.; Barrett, C.; Wu, J. J. Appl. Phys. **2010**, 108, 083538.
- (46) Rúa, A.; Fernández, F. E.; Sepúlveda, N. J. Appl. Phys. 2010, 107, 074506.
- (47) Wang, K. X.; Cheng, C.; Cardona, E.; Guan, J. Y.; Liu, K.; Wu, J. ACS Nano 2013, DOI: 10.1021/nn305419e.
- (48) Mirfakhrai, T.; Madden, J. D. W.; Baughman, R. H. Mater. Today 2007, 10, 30.
- (49) Liu, K.; Fu, D. Y.; Cao, J.; Suh, J.; Wang, K. X.; Cheng, C.; Ogletree, D. F.; Guo, H.; Sengupta, S.; Khan, A.; Yeung, C. W.; Salahuddin, S.; Deshmukh, M. M.; Wu, J. *Nano Lett.* **2012**, *12*, 6272.
- (50) Nakano, M.; Shibuya, K.; Okuyama, D.; Hatano, T.; Ono, S.; Kawasaki, M.; Iwasa, Y.; Tokura, Y. *Nature* **2012**, *487*, 459.